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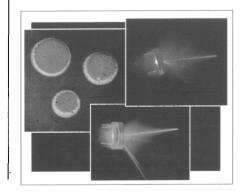
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Stability of Microstructure in Metallic Systems, 2d ed., J.W. Martin, R.D. Doherty, and B. Cantor, reviewed by I. Baker; The Substance of Civilization: Materials and Human History from the Stone Age to the Age of Silicon, S.L. Sass, reviewed by R. Cahn; Reflection Electron Microscopy and Spectroscopy for Surface Analysis, Z.L. Wang, reviewed by P.M. Ajayan and V. Ravikumar.

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ON THE COVER: Diffraction of blue (488 nm) (Top Right) and green (514.5 nm) (Bottom Right) laser beams by a photonic crystal prepared from a crystalline face-centered-cubic array of polystyrene colloids. (Left) Photonic-crystal chemical-sensing

(Left) Photonic-crystal chemical-sensing material. The photonic crystal normally diffracts violet light. The presence of three drops of a lead solution swells the photonic crystal and shifts the diffracted color to red. This is an example of a new chemical sensing motif.

For more information, see the article by S.A. Asher et al. on p. 44 of this issue.

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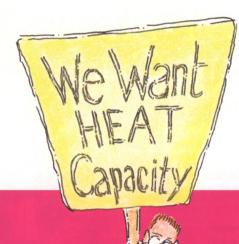
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Sample courtesy A.P. Shilov, Aoscow State University, 25µm Surface correlating dislocation pits and tree carrier concentration, 2.5um

Background: MFM image of a Fe_{ab}B₁₆Si₄ ribbon revealing stress-induced magnetic structure that can lead to power losses in electrical transformers, 30µm scan courtesy M.E. Hawley, Los Alamos National Lab



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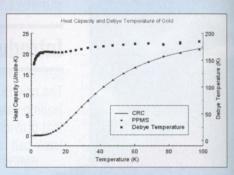
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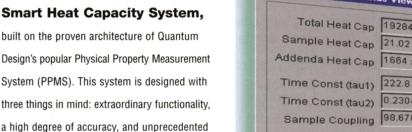
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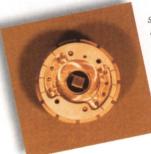
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A sophisticated fitting technique called the *two-tau model* enables the system to accurately simulate the effect of heat flow between the micro-calorimeter chip and the sample (tau1), as well as the heat flow between the chip and the sample mount (tau2).



Heat capacity of a gold sample on the PPMS in comparison with CRC values. Each triangle is three overlapping symbols, there has been no averaging.





ease of use.

Sample mount: Heater and thermometer are deposited directly on the micro-calorimeter chip for improved sample coupling and reliability.

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Sample Heat Cap Addenda Heat Cap Time Const (tau1) Time Const (tau2) Sample Coupling Base Samp Temp Avg Samp Temp	19284 ± 13 µJ/K 21.02 ± 0.02 J/mole-K 1664 ± 0.64 µJ/K 222.8 sec 0.2304 sec 98.6761 % 96.8987 K 97.8787 K 1.9599 K	Substrate Temp (fb) Substrate Temp (measured) 98.8 98.6 98.4 98.2 98.4 98.2 98.4 98.2 98.4 98.2 97.8 97.4 97.2 97.0	Sample Temp (from ft) Heater Power (messur
	0.80483 184.43 ± 0.42 K Save Time Trace	50	100 150 200 ime (sec) Undo Zo mi Close
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